

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Kwang Choe et al.

Examiner: Padgett, Marianne L.

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Title: SOI BY OXIDATION OF
POROUS SILICON

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Commissioner for Patents
P.O. Box 1450
Alexandria, VA. 22313

RESPONSE AND AMENDMENT UNDER 37 C.F.R. § 1.111

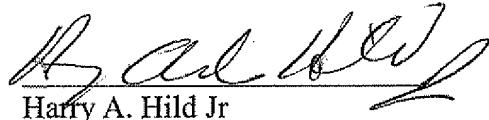
Sir:

In response to the Office Action dated June 25, 2008, Applicants submit the following amendments and remarks for entry of record in the above-identified application.

CERTIFICATE OF ELECTRONIC FILING

I hereby certify that this correspondence is being deposited with the United States Patent & Trademark Office via Electronic Filing through the United States Patent and Trademark Office e-business website, on September 24, 2008.

Dated: September 24, 2008



Harry A. Hild Jr.